TITLE: High dielectric constant of polymer-inorganic nanocomposites as gate dielectrics for organic thin film transistor applications

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ABSTRACT

Organic thin film transistors (OTFTs) based pentacene and hydroxyl-containing polyimide-zirconium dioxide (PI-ZrO₂) hybrid films were fabricated on silicon substrate in which the PI and ZrO2 were as the semiconductor and the gate dielectrics, respectively. Zirconium butoxide (Zr(OBu)₄) was used as the precursor to synthesize nano-sized ZrO₂ colloid through the hydrolysis and condensation reaction in a sol-gel process. Then, PI-ZrO2 hybrid solution was synthesized from a condensation reaction between hydroxyl-containing ZrO2 and polyimide, followed by a spin coating to form the PI-ZrO₂ dielectric composites. Cyclic olefin copolymer (COC) was used as a modify layer to enhance the interface property between the semiconductor and the dielectric layer. In addition, PffBT4T-2OD was replaced by pentacene as semiconductor to expect a good performance on device. The thermal, optical, surface, dielectric, and electrical properties of the PI-ZrO₂ dielectric composites were investigated and correlated to ZrO₂ content due to the dispersion and aggregation behaviors of the nanoparticles. The PI-ZrO₂ hybrid dielectrics showed the tunable insulating properties, including high dielectric constants, high capacitances, and low leakage current densities. Besides, the bottom-gate top-contact OTFTs based on the PI-ZrO₂ hybrid dielectrics PZ30% and PZ30%-COC showed the best performance with the near zero threshold voltage and the field-effect mobility (µ) about 1.12 cm²V⁻¹s⁻¹ and 3.25 cm²V⁻¹s⁻¹ and the current on/off ratio (I_{on}/I_{off}) about $1.2x10^4$ and $1.2x10^6$, respectively. Based on the above results, PI-ZrO₂ hybrid dielectrics were synthesized and the OTFTs based on the PI-ZrO2 hybrid dielectrics and pentacene were fabricated successfully. The best performance for OTFTs was obtained when the ZrO2 content in hybrid films was 30%.

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Keywords: polyimide, Zirconia, hybrid thin film, sol-gel method, modify layer